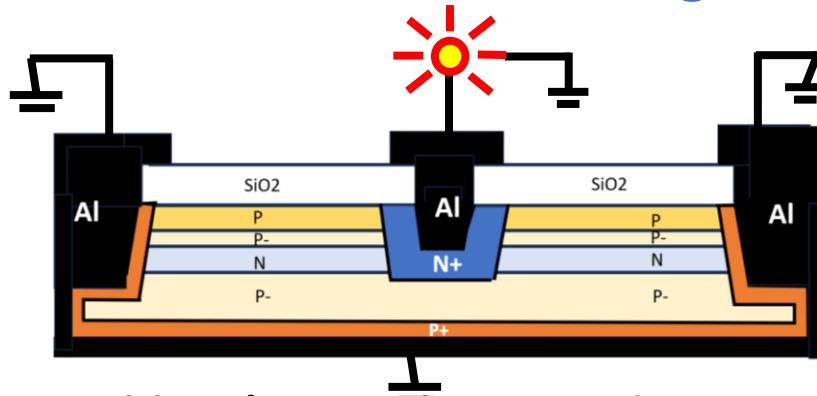
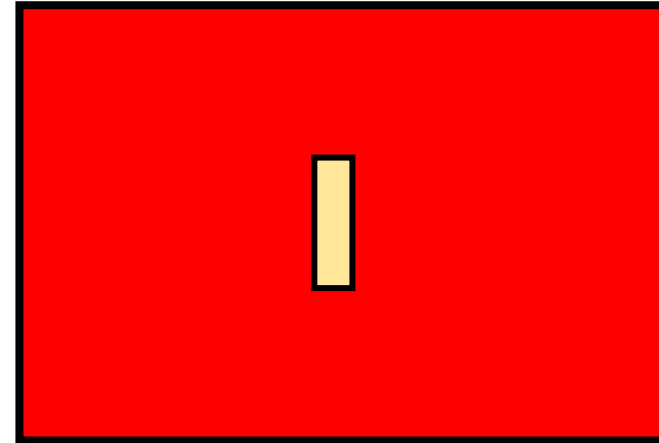


008 Mask 01 SiO₂ Etching



Positive Photo Resist は光が照射した部分のみが溶液で解けて除去できます。



<https://lushbooklife.com/news-of-positive-photoresist/>

Positive Photo Resist		Positive Photo Resist	
SiO ₂		SiO ₂	
P		P	
P-		P-	
N		N	
P-		P-	